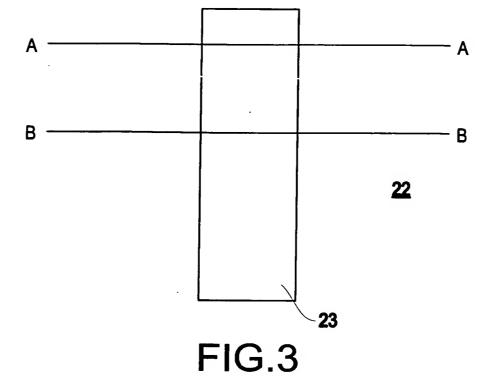


MASKING LAYER 1	23
SILICON	
BURIED OXIDE	21
SUBSTRATE	

FIG.2





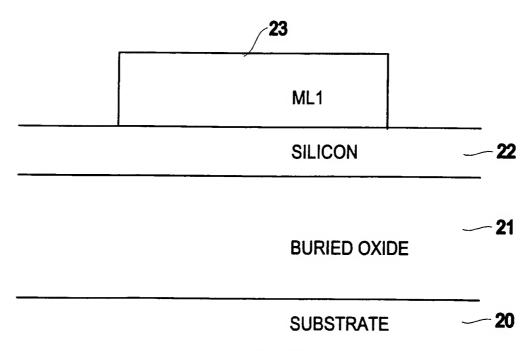
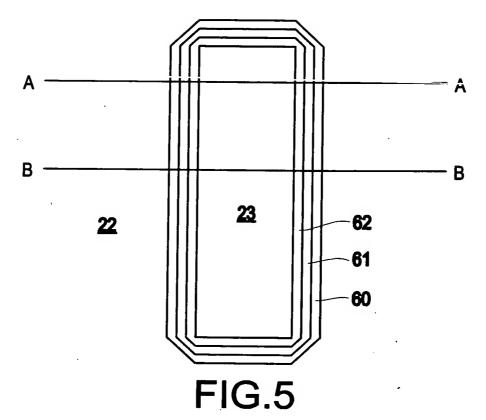


FIG.4





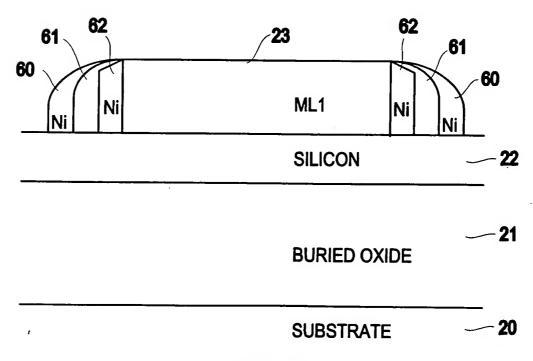
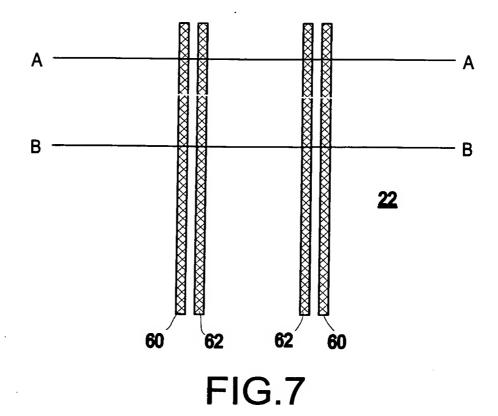


FIG.6





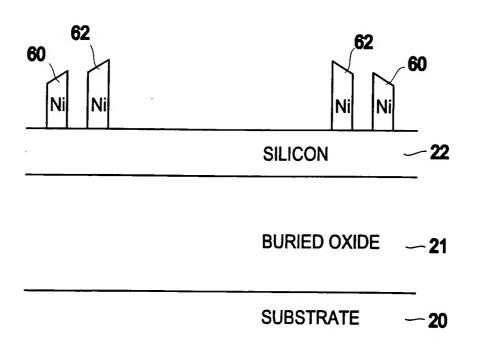


FIG.8



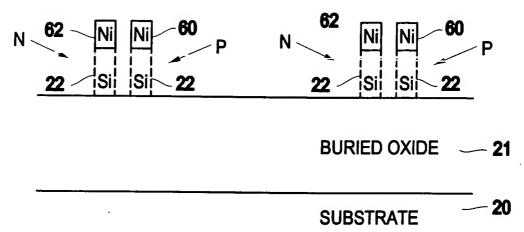


FIG.9

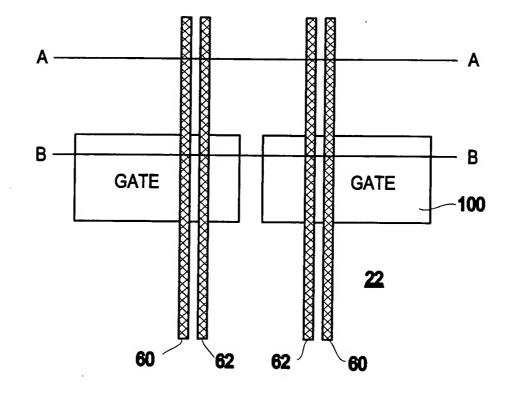


FIG.10





BURIED OXIDE — 21

SUBSTRATE — 20

FIG.11

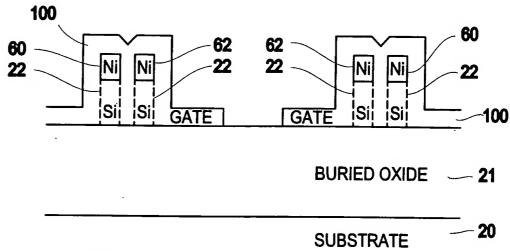
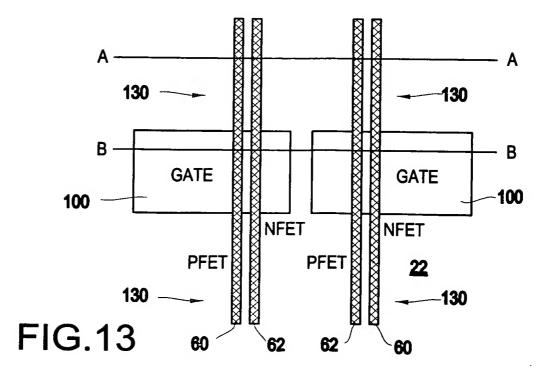
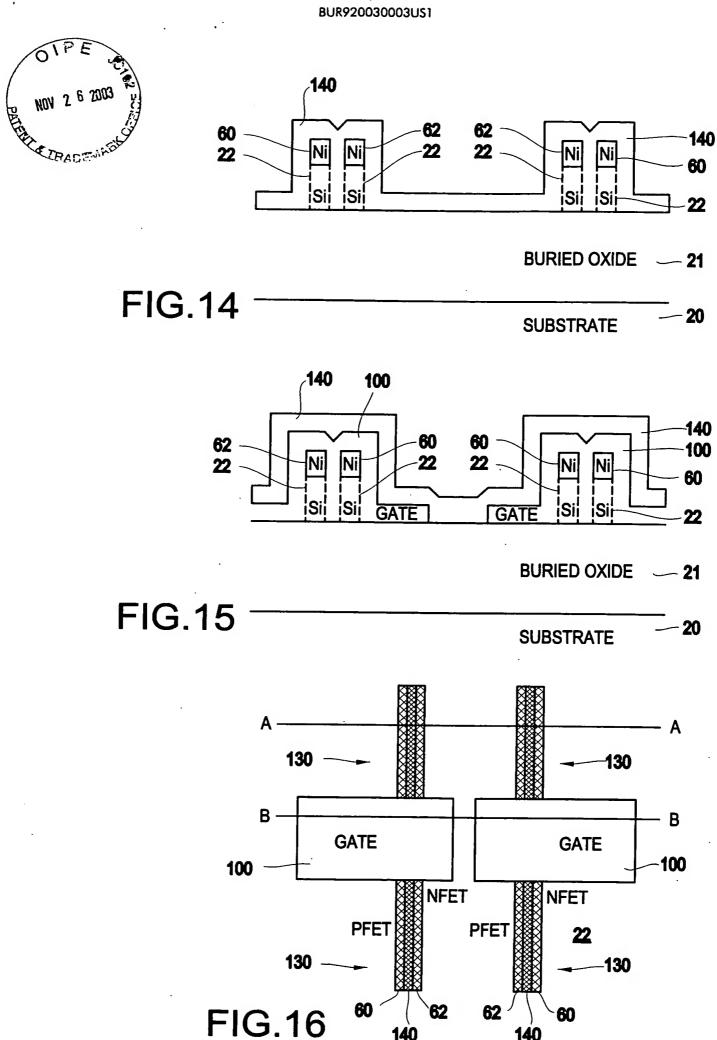
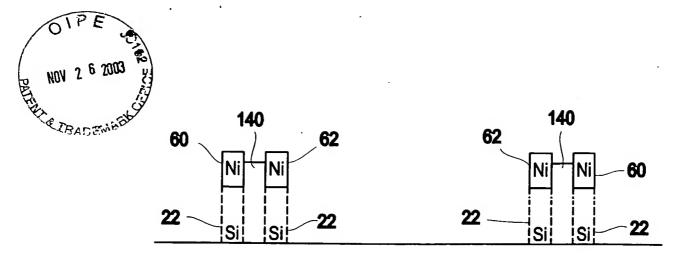


FIG.12







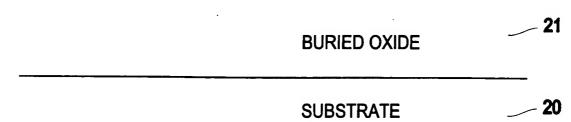
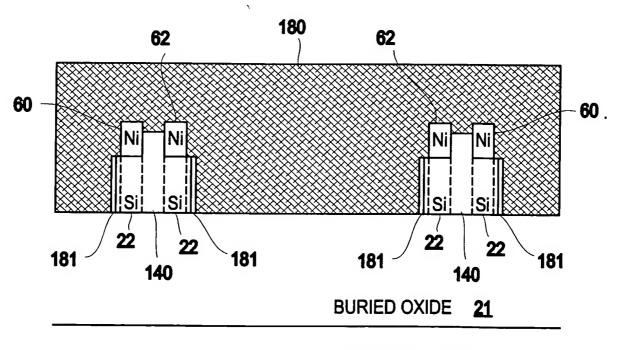


FIG.17



SUBSTRATE 20

FIG.18

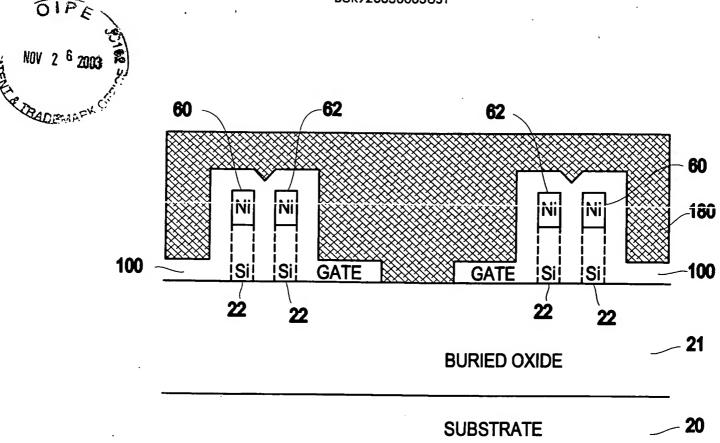


FIG.19

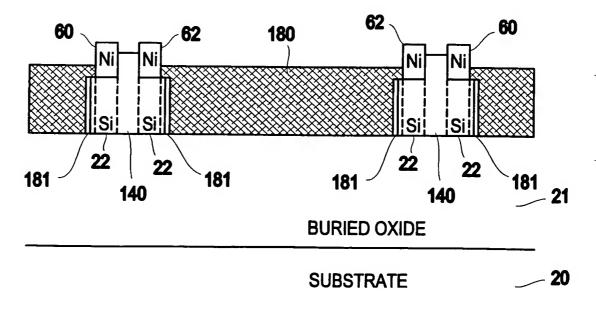


FIG.20



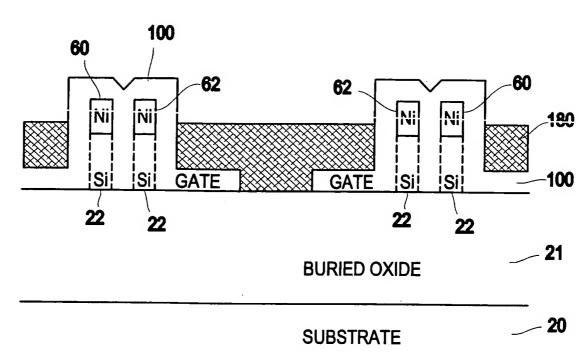


FIG.21

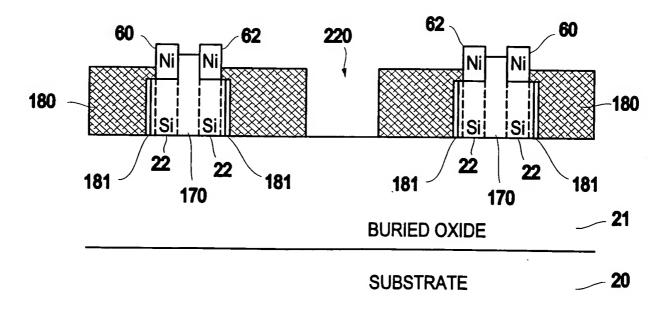


FIG.22

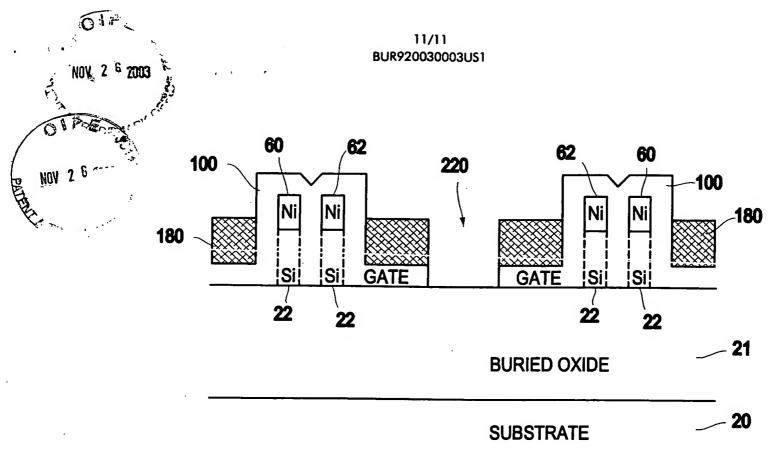


FIG.23

